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Cu-Deficient Plasmonic Cu_{2-x}S Nanoplate Electro-catalysts for Oxygen Reduction

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ABSTRACT: Cation deficient transition metal sulfides have attracted increased attention due to their unique properties that arise from degenerate *p*-doping, particularly their localized surface plasmon resonance (LSPR) and related optical properties. Here, we present the first study of their electrocatalytic activity. We developed a facile one-pot method to prepare *p*-doped copper sulfide nanoplates with tunable LSPR at moderate temperature (below 100°C) without any hot injection or rapid mixing step. The doping level was controlled by varying the concentration of cation precursor (Cu²⁺) to finely tune the LSPR wavelength without changing the nanoplate size or morphology. Cu_{2-x}S nanoplates with three different doping levels were tested for their electrocatalytic activity for the oxygen reduction reaction (ORR) in alkaline solution. Importantly, increasing the concentration of free holes in Cu_{2-x}S significantly enhanced the ORR catalytic activity. Furthermore, to improve the electrical conductivity, the most heavily doped Cu_{2-x}S nanoplates were deposited on carbon black (Vulcan XC-72) and reduced graphene oxide (rGO), thereby leading to substantial enhancement of ORR steady-state current in both electrochemical and mass-transfer controlled potential regions. A calculation of average electron transfer number along with the measured peroxide yield indicated that both carbon black and rGO supported Cu_{2-x}S catalysts can provide a four-electron reduction pathway. The ORR catalytic activity of the Cu_{2-x}S nanoplates does not yet match that of state-of-the-art Pt/C catalysts. However, this work opens up new opportunities to apply *p*-doped copper chalcogenides as electrocatalysts for the ORR beyond conventional nonprecious metal catalysts based upon Fe, Co, N, and C.

KEYWORDS: *colloidal synthesis, localized surface plasmon resonance, oxygen reduction reaction, electrocatalyst, reduced graphene oxide, copper sulfide*

Introduction

Copper chalcogenides (Cu_xE with E=S, Se, or Te and *x* from 1 to 2) with bandgap energies of 1.0 to 1.5 eV have been drawing increasing attention due to their unique properties and potential application in low-cost solution-processed electronic¹⁻³ and optoelectronic devices.⁴⁻⁸ Recently, localized surface plasmon resonance (LSPR) has been observed in copper-deficient copper chalcogenide nanocrystals (NCs).⁹⁻¹³ The LSPR is due to collective oscillation of the free holes created by copper deficiency.¹⁴ This differs from the LSPR observed in noble metal NCs^{15,16} (i.e. Au and Ag) which is mediated by free electrons. Resonance between charge carrier oscillations and the frequency of incident light produces intense extinction bands at near-infrared (NIR) wavelengths.^{13,17} This property opens up potential applications such as plasmonic optoelectronics devices,¹⁸ sensors¹⁹ and

theranostics.¹⁹⁻²¹ The peak LSPR extinction wavelength in copper chalcogenide NCs depends upon the concentration of free holes, directly associated with the stoichiometry of the NCs. Lower Cu content (increasing Cu deficiency) produces a higher concentration of holes, resulting in an increase in the LSPR energy, i.e., a blue-shift of the wavelength of LSPR extinction peak.²² As for anisotropic NCs, the LSPR wavelength also depends upon the aspect ratio.

Because the LSPR depends upon the doping level of the NCs, one may reasonably assume that catalytic activity of the NCs would be correlated with their LSPR. However, to the best of our knowledge, the electrocatalytic properties of such degenerately-doped copper chalcogenide NCs have not yet been explored. Electrocatalysis is a subject of great recent interest due to its important role in fuel cells, electrolysis, and other energy storage and conversion applications. In

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general, electrocatalytic activity depends strongly on charge transfer at electrode/electrolyte interfaces. These free hole-rich copper chalcogenides may provide a new opportunity to develop novel electrocatalysts. Motivated by this, we studied Cu-deficient Cu_{2-x}S as an efficient catalyst for the oxygen reduction reaction (ORR), one of the most important reactions for a wide variety of electrochemical energy technologies such as polymer electrolyte fuel cells (PEFCs) and metal–air batteries (MABs).²³⁻²⁶ Platinum has long been known as the most effective catalyst to facilitate ORR in terms of its activity and stability, but its scarcity and high cost limit widespread implementation of these clean energy technologies.²⁶⁻²⁸ Thus, development of alternative nonprecious metal catalysts is a key step needed to scale up these clean energy technologies. To date, the most promising nonprecious metal catalysts studied for the ORR are derived from Fe/Co, N, and C through a high-temperature approach.²⁹⁻³³ However, their activity and stability are still insufficient.^{34,35} Continued effort is still required to further explore new types of nonprecious metal catalysts.

Here, we provide the first demonstration that the plasmonic copper sulfide (Cu_{2-x}S) nanocrystals (NCs) can serve as a highly active ORR electrocatalyst in alkaline media. Monodisperse colloidal Cu_{2-x}S nanoplates with tunable LSPR were produced using a facile and scalable one-pot approach that does not require precursor injection at high temperature. The synthesis is tunable to optimize the electrochemical properties of the NCs. Notably, copper sulfide (Cu_{2-x}S) is composed of relatively non-toxic, low cost, and earth-abundant elements, and sulfur is preferred over the other chalcogenide elements on this basis. The band structures of the various possible crystal phases of Cu_{2-x}S exhibit stoichiometry-dependent bandgap and Fermi level. During the colloidal synthesis, we focus on the inherent correlations among elemental composition, morphology, crystal phase, and optical properties. The LSPR energy is strongly influenced by the Cu:S precursor ratio used during the synthesis. In this study, the most heavily doped Cu_{2-x}S nanoplates (lowest Cu content and highest LSPR energy) exhibited the best ORR activity. The electrochemical activity of Cu_{2-x}S was further enhanced when the NCs were deposited on carbon black (Vulcan XC-72) or reduced graphene oxide (rGO). These results suggest that the Cu-deficient Cu_{2-x}S can be a new class of nonprecious metal electrocatalysts for the ORR.

Experimental Section

Chemicals. Copper(I) chloride (CuCl , 99.995%), oleylamine (OAm, 70%), sulfur (S) powder (99.98%) and trioctylphosphine oxide (TOPO, technical grade 90%) were purchased from Sigma Aldrich and were used as-received.

One-Pot Synthesis of Cu_{2-x}S Nanoplates. In a typical procedure, a selected quantity of CuCl (0.25, 0.375 or 0.5 mmol) was mixed with 1 mmol S powder, 4 g trioctylphosphine oxide (TOPO) and 10 mL oleylamine (OAm). The solution was degassed at room temperature under nitrogen protection followed by heating to 85 °C and maintaining this temperature for 1 h. After that, the heating mantle was removed and 20-30 ml ethanol was injected, reducing the temperature to ~40 °C. Cu_{2-x}S samples were collected by centrifugation at 9000 rpm (about 9000 G) for 1 min. The collected Cu_{2-x}S samples were redispersed in chloroform. This procedure was repeated twice to purify the prepared Cu_{2-x}S . Finally, the resulting samples were dispersed in chloroform for subsequent characterization and tests.

Preparation of Carbon (C) Supported and Reduced Graphene Oxide (rGO) Supported Cu_{2-x}S Nanoinks. Carbon black (Vulcan XC-72) was used to support the Cu_{2-x}S nanoplates. In a typical procedure, 10 mg of carbon black was dispersed in 1.0 mL Cu_{2-x}S (~2 mg/mL) dispersion with 1.0 mL chloroform added and sonicated for 1 h at room temperature. The resulting dispersion was used to produce thin film electrodes with Cu_{2-x}S content of 17 wt% for electrochemical measurements. Similarly, rGO supported Cu_{2-x}S inks were produced by mixing 3.0 mg rGO (purchased from Graphene Supermarket with a surface area of 290 m²/g), 0.3 mL Cu_{2-x}S (~2 mg/mL) dispersion, and 0.2 mL chloroform *via* sonication for 1 h at room temperature. This results in a final material with the same Cu_{2-x}S content of ~17 wt%.

Material Characterization.

Transmission Electron Microscopy (TEM). The size and morphology of Cu_{2-x}S NCs were characterized using a JEOL JEM-2010 microscope at a working voltage of 200 kV.

Powder X-Ray Diffraction (XRD). The crystal phases of Cu_{2-x}S NCs were determined using powder XRD (Bruker Ultima IV with Cu K- α X-rays). Samples were prepared by drop-casting high-concentration Cu_{2-x}S NC dispersions onto glass slides.

Energy Dispersive X-Ray Spectroscopy. Compositional analysis of Cu_{2-x}S NCs was obtained using an Oxford Instruments X-Max 20 mm² energy

dispersive X-ray spectroscopy (EDS) detector within a Zeiss Auriga scanning electron microscope (SEM)

UV-Vis-NIR Spectroscopy. Optical absorption spectra of Cu_{2-x}S NCs dispersions were measured using a Shimadzu 3600 UV-visible-NIR scanning spectrophotometer.

Electrochemical measurements. To determine the electrocatalytic activity for the ORR, rotating disc electrode (RDE) measurements using Cu_{2-x}S catalysts were performed in a conventional three-electrode cell with 0.1 M NaOH solution at room temperature. A graphite rod and an Ag/AgCl electrode (KCl-sat., 0.996 V vs. RHE) were used as the counter and reference electrodes, respectively. The Cu_{2-x}S or supported Cu_{2-x}S was drop-cast onto a glassy carbon electrode (0.245 cm^2 area) and dried under a heating lamp to achieve an adherent film with the desired loading. The loading of Cu_{2-x}S was controlled at 80 $\mu\text{g}/\text{cm}^2$ for all tests. For carbon black and rGO supported Cu_{2-x}S catalysts, the loading of Cu_{2-x}S was still kept at 80 $\mu\text{g}/\text{cm}^2$. In RDE tests, ORR steady-state polarization curves were recorded in oxygen-saturated 0.1 M NaOH solutions with potential steps of 0.03 V at intervals of 30 s. Disk rotation rates of 400, 900, 1600 and 2500 rpm were used. The Pt/C reference catalyst used in this work is 20 wt% E-TEK Pt/Vulcan XC-72.

Results and Discussion

A facile synthetic method was developed to prepare monodisperse Cu_{2-x}S nanocrystals (NCs) by heating copper salt and sulfur powder at a moderate temperature ($\sim 85^\circ\text{C}$) in a solution containing oleylamine and TOPO. To the best of our knowledge, no prior reports have used sulfur powder as the S donor during the one-pot synthesis of colloidal plasmonic copper sulfide NCs below 100°C . Many previous reports of the synthesis of Cu_{2-x}S , used temperatures above 200°C .^{9,36} With elemental sulfur dissolved in oleic acid or oleylamine as the sulfur precursor, homogeneous Cu_{2-x}S nanoparticles can be grown above 105°C , following hot-injection at higher temperature, usually above 140°C .^{12,37} Other methods using dodecanethiol or ammonium diethyldithiocarbamate/ dodecanethiol mixtures typically employ temperatures from 120 to 200°C .³⁸⁻⁴⁰

Here, through our selection of precursors and ligands, we were able to synthesize copper sulfide NCs using moderate heating ($< 100^\circ\text{C}$) of a mixture of CuCl, S, TOPO, and oleylamine. During heating, the color of the solution gradually turned to dark brown, indicating the formation of nuclei and growth

of NCs. During the low-temperature synthesis, the process of formation of organo-cation and organo-anion complexes and the NC nucleation can occur at the same time. Numerous previous studies succeeded in using organic molecules and appropriate precursors to achieve high quality NCs with tunable physical and chemical properties. Here, we demonstrate that the optical properties can be manipulated by varying the concentration of cations in the precursor mixture. Figure 1 shows TEM images of highly monodisperse Cu_{2-x}S nanoplates obtained using 0.25, 0.375 and 0.5 mmol of CuCl in the synthesis, each with an average lateral diameter of ~ 21 nm. The size and morphology of the Cu_{2-x}S nanoplates did not alter with changes in the Cu precursor concentration. The thickness of nanoplates was in the range of 2.5-3.5 nm and nanoplates tended to assemble face-to-face into columns (Supporting Information Figure S2).

Energy dispersive X-ray spectroscopy (EDS) provided elemental composition of Cu and S in the final Cu_{2-x}S nanoplates. The EDS results showed that the copper content in the final products decreased with increasing amount of CuCl supplied during the synthesis, from 0.25 mmol to 0.5 mmol with a constant 1 mmol of sulfur. Figure 2A shows the relationship between the Cu cation fraction in Cu_{2-x}S

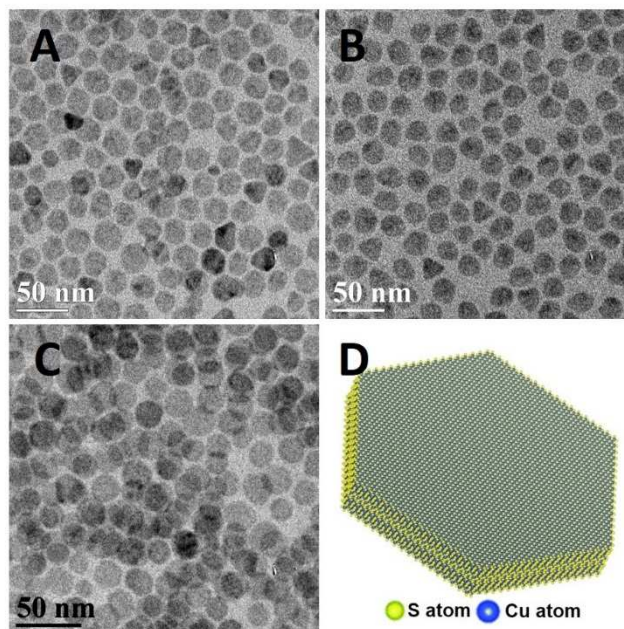


Figure 1. TEM images of Cu_{2-x}S nanoplates synthesized using a one-pot method with varying Cu precursor amount. The CuCl used and resulting average diameter are (A) 0.25 mmol, 22.4 ± 2.4 nm; (B) 0.375 mmol, $21.2 \pm$ nm; (C) 0.5 mmol, 21.4 ± 2.2 nm, respectively. (D) A ball-and-stick model of a Cu_{2-x}S nanoplate of covellite crystal structure with diameter of ~ 20 nm and thickness of ~ 3 nm. Size distributions are shown in Supporting Information figure S2. They are approximately Gaussian with the standard deviations given above.

and mole amount of CuCl used in the synthesis. In particular, the Cu content dropped 4.1% from 50.6% to 46.5% upon doubling the Cu precursor amount. Although this trend is somewhat counter-intuitive, one should note that in this single-pot method, precursor dissolution and complexation of Cu and S can occur simultaneously with nanoparticle nucleation and growth. Thus, while providing more CuCl produces a higher copper concentration in solution after all precursors have dissolved, it does not necessarily produce a higher Cu concentration in solution during initial stages of particle nucleation and growth when the CuCl has not yet fully dissolved. Although the mechanism behind this observation is not yet clear, and merits further study, it was consistently reproducible. Despite the changes in Cu content in Cu_{2-x}S , the plate-like morphology and size remained unchanged. Figure 2B shows the XRD patterns of the Cu_{2-x}S NCs as a function of the amount of CuCl provided. They were consistent with PDF card No. 04-004-8686 for hexagonal covellite. The main peaks were indexed to the (1,0,1), (1,0,2), (1,0,3), (1,1,0) and (2,0,3) planes. No obvious shift was detected upon increasing the amount of CuCl provided. The (1,1,0) peak was significantly sharper than other peaks, suggesting anisotropic growth of oriented plate- or disk-like structures during this low temperature one-pot synthesis.⁴¹ More detailed studies of the mechanism of anisotropic growth of metal sulfide NCs in this process are a promising area for future study.

UV-vis-NIR absorbance spectra were measured to characterize the LSPR in Cu_{2-x}S . Free holes in *p*-doped semiconductor NCs produce strong LSPR. The LSPR energy is directly dependent upon the free carrier concentration, which in turn depends upon the copper content. Several methods of tuning the plasmonic properties in those semiconductor NCs have been reported, including stepwise oxidation-reduction^{42,43}, tuning the aspect ratio of anisotropic nanostructures⁴⁴, cation exchange,^{10,45} and

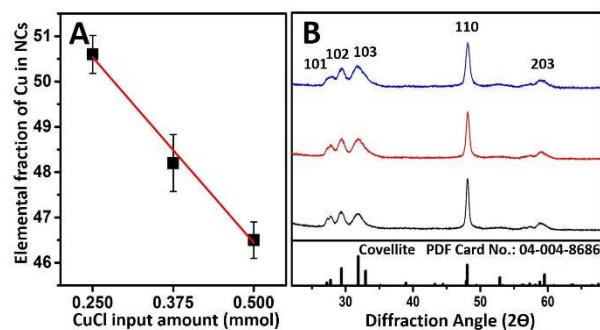


Figure 2. (A) Dependence of Cu content in Cu_{2-x}S NCs upon the amount of CuCl precursor used in synthesis. (B) XRD patterns of Cu_{2-x}S nanoplates synthesized using 0.25 mmol (black curve, bottom), 0.375 mmol (red curve, middle) and 0.5 mmol (blue curve, top) of CuCl.

manipulating the surface chemistry of NCs.^{12,13} Here, we found that the LSPR in these copper sulfide nanoplates is tunable by simply changing the amount of CuCl provided during the one-pot synthesis. To confirm that the observed absorbance arises from LSPR, we tested its dependence upon the refractive index of the NC's surroundings. Figure 3A shows a red-shift of the NIR absorbance with increasing refractive index of the solvent in which Cu_{2-x}S were dispersed. The peak of the LSPR absorbance was red-shifted nearly 150 nm from hexane to carbon disulfide. This red-shift of absorbance with increasing refractive index of the solvent is a hallmark behavior of LSPR. The resonance in polarizability of the NC is associated with the relative dielectric constants of the NC and the surroundings.^{9,22} Meanwhile, as shown in Figure 3B, the Cu_{2-x}S sample synthesized using 0.5 mmol Cu precursor shows a dominant LSPR peak at 1290 nm, in chloroform. Upon reducing the CuCl amount from 0.5 mmol to 0.375 mmol and 0.25 mmol, the LSPR peak red-shifted to 1450 nm and 1540 nm, respectively. Thus, by varying the amount of CuCl provided during the synthesis of copper sulfide NCs, we can easily tune the plasmonic properties and manipulate the doping level of the particles. XRD and TEM studies further indicated that the crystal structure, morphology and size of Cu_{2-x}S nanoplates were independent of copper precursor amount. However, because the Cu content decreased with increasing amount of CuCl provided, the free carrier concentration increased with increased amount of CuCl provided, resulting in a blue shift of the LSPR with increased amount of CuCl provided. This provides a straightforward new mean of adjusting the concentration of free holes in these NCs.

Because electrocatalytic performance for the ORR depends upon charge transfer at the electrode interface, correlation of electrocatalytic activity with LSPR wavelength and corresponding concentration of free holes is of interest. To this end, Cu_{2-x}S nanoplates

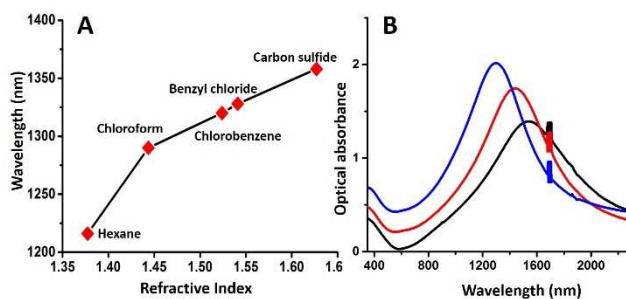


Figure 3. Optical properties of Cu_{2-x}S NCs. (A) Dependence of LSPR absorbance peak wavelength on solvent refractive index for Cu_{2-x}S NCs synthesized using a 0.5 mmol Cu precursor (B) Absorbance spectra of Cu_{2-x}S NCs synthesized using Cu precursor input amounts of 0.5 mmol (blue curve), 0.375 mmol (red curve) and 0.25 mmol (black curve), in CHCl_3 .

were systematically studied as an electrocatalyst for the ORR in alkaline solution. Cu_{2-x}S nanoplates were drop-deposited as thin films on the surface of glassy carbon electrodes at a constant mass loading ($80 \mu\text{g}/\text{cm}^2$). ORR steady-state polarization plots for each sample of Cu_{2-x}S nanoplates were recorded at a rotation rate of 900 rpm and room temperature, are shown in Figure 4A. The Cu_{2-x}S catalyst synthesized using 0.5 mmol Cu precursor (Cu_{2-x}S -0.5) showed the best activity, compared to samples prepared using 0.25 (Cu_{2-x}S -0.25) and 0.375 mmol (Cu_{2-x}S -0.375), as evidenced by the most positive half-wave potential ($E_{1/2}$) of 0.70 V. Lower $E_{1/2}$ of 0.64 V and 0.62 V were measured with Cu_{2-x}S -0.375 and Cu_{2-x}S -0.25, respectively. In addition, the onset potential of the ORR for Cu_{2-x}S -0.5 was as high as 0.90 V, which is much more positive than those of Cu_{2-x}S -0.375 (0.85 V) and Cu_{2-x}S -0.250 (0.75 V). This suggests that nature of the active sites is changed due the increased copper deficiency in Cu_{2-x}S -0.5. According to EDS and plasmonic peak analysis, Cu_{2-x}S NCs derived from 0.5 mmol Cu precursor were the most heavily

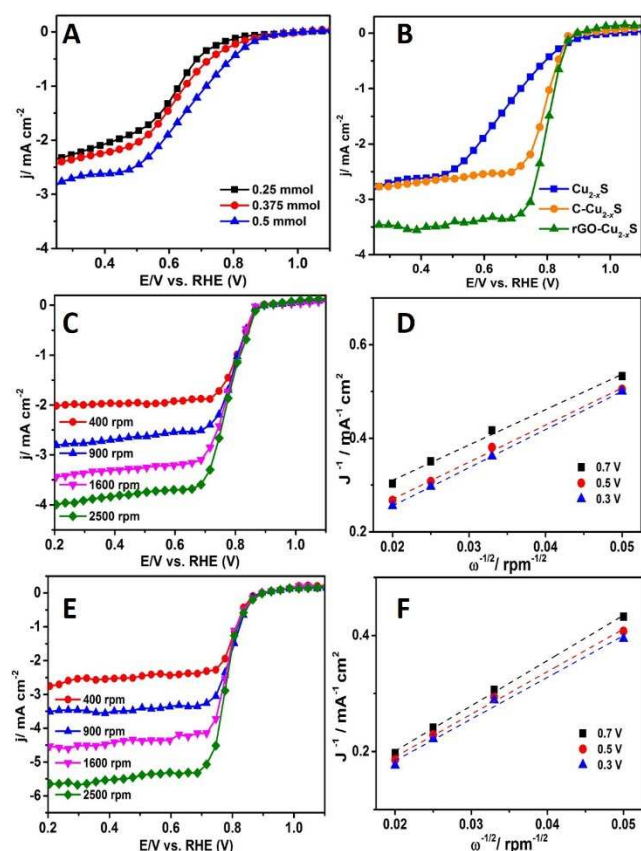


Figure 4. (A) ORR steady-state polarization curves of Cu_{2-x}S NCs synthesized using 0.25 mmol, 0.375 mmol and 0.5 mmol Cu precursors. (B) steady-state polarization curves for Cu_{2-x}S NCs, C- Cu_{2-x}S and rGO- Cu_{2-x}S . (C&E) ORR steady-state polarization curves for C- Cu_{2-x}S (C) and rGO- Cu_{2-x}S (E) with varying electrode rotation rates. (D&F) Koutecky-Levich plots of the ORR for C- Cu_{2-x}S (D) and rGO- Cu_{2-x}S (F). The measurements were performed in O_2 -saturated NaOH.

doped NCs. Given the nearly identical crystal structures, morphologies, and sizes for the three samples, the much increased catalytic activity measured with the Cu_{2-x}S -0.5 sample is attributed to its significantly higher concentration of free holes, providing more active sites for the ORR. To the best of our knowledge, this is the first report using metal deficient plasmonic sulfide NCs as an efficient electrocatalyst for the ORR.

In order to further improve the electrocatalytic performance by enhancing electrical conductivity and utilization of active catalysts, the Cu_{2-x}S nanoplates were deposited on Vulcan XC-72 carbon black and rGO through a self-assembly approach in solution. Figure 5 shows typical TEM images of the Cu_{2-x}S -0.5 NCs anchored on Vulcan XC-72 (Figure 5A, C- Cu_{2-x}S) and rGO (Figure 5B, rGO- Cu_{2-x}S). The Cu_{2-x}S NCs self-assembled onto both carbon supports during mild sonication in chloroform solution. Steady-state RDE measurements were then carried out to study ORR activity and kinetics on C- Cu_{2-x}S and rGO- Cu_{2-x}S catalysts. Figure 4B shows typical polarization curves recorded in O_2 -saturated 0.1 M NaOH solution at a rotation rate of 900 rpm and room temperature. Compared to Cu_{2-x}S alone, both carbon supported C- Cu_{2-x}S and rGO- Cu_{2-x}S exhibit dramatically increased current densities in the kinetic potential region, with well-defined limiting currents. Both supported catalysts showed more positive half-wave potentials $E_{1/2}$ (C- Cu_{2-x}S 0.80 V, rGO- Cu_{2-x}S 0.82 V), relative to Cu_{2-x}S NCs alone (0.70 V). This indicates that using XC-72 carbon black or rGO as the catalyst support leads to a significant increase in the number of active sites for the ORR. Importantly, the activity improvement using rGO was greater than that using XC-72 as the support, as evidenced by more positive half-wave potentials and larger limiting currents. As discussed in previous reports,^{30,46,47} the advantages of reduced graphene oxide (rGO) for electrocatalysis arise from its high-surface area, excellent electrical conductivity, electrochemical stability, and unique two-dimensional planar morphology.³¹ We also studied the catalytic activity of the Vulcan XC-72 and rGO without Cu_{2-x}S NCs, as shown in Figure S4. These

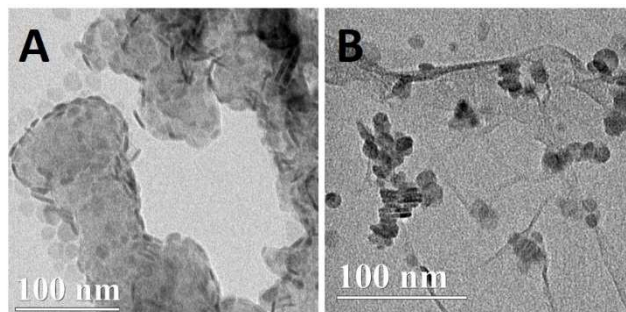


Figure 5. TEM images of Cu_{2-x}S nanoplates deposited on carbon black (C- Cu_{2-x}S , A) and reduced graphene oxide (rGO- Cu_{2-x}S , B).

support materials had much lower activity than the C-Cu_{2-x}S or rGO-Cu_{2-x}S. This result confirms that the significant enhancement of rGO-Cu_{2-x}S is derived from the remarkable support effort of rGO and not from any intrinsic electrocatalytic activity of the rGO itself. In addition, the limiting current density for the ORR was improved when rGO was used for supporting Cu_{2-x}S nanocrystals. Although the limiting current density of planar disk electrodes is theoretically governed by rotation rate during the ORR experiments, based on the Koutecky-Levich equation, an increasing body of evidence shows that increased porous structures and surface areas of electrodes play an important role in enhancing limiting current.⁴⁸ In this work, the high-surface area and excellent electrical conductivity of graphene (rGO) lead to significantly enhanced limiting currents, relative to unsupported Cu_{2-x}S nanocrystals. Thus, the high activity for the ORR measured with the rGO-Cu_{2-x}S not only originates from heavily *p*-doped Cu_{2-x}S but is also further enhanced by the unique rGO support effect.

Furthermore, the electrocatalytic activity for the C-Cu_{2-x}S and rGO-Cu_{2-x}S were quantitatively examined at several electrode rotation rates of 400, 900, 1600, and 2500 rpm. Figure 4C and 4E show the rotation-speed controlled current densities of the ORR measured with of C-Cu_{2-x}S and rGO-Cu_{2-x}S catalysts, respectively. The corresponding Koutecky-Levich (K-L) plots as a function of different ORR working potentials are shown in 4D and 4F, with a correlation between the inverse current density (j^{-1}) and the inverse of the square root of rotation rate ($\omega^{-1/2}$). The number of electrons involved per O₂ reduction on carbon supported Cu_{2-x}S catalysts was calculated according to the modified K-L equation for a film-coated electrode.⁴⁹ As a result, the number of

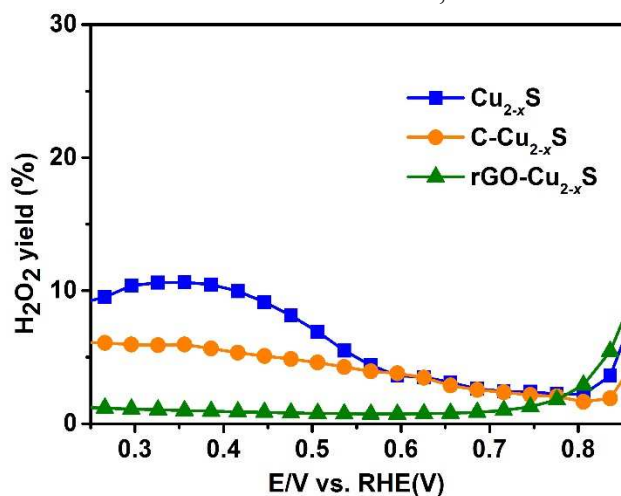


Figure 6. H₂O₂ yield plots measured with the Cu_{2-x}S, C-Cu_{2-x}S and rGO-Cu_{2-x}S catalysts in O₂-saturated 0.1 M NaOH at room temperature with rotation rate of 900 rpm.

electrons n calculated for rGO-Cu_{2-x}S is 3.67-3.98, which is slightly larger than that for C-Cu_{2-x}S (3.50-3.78), thereby suggesting a four-electron (4e⁻) O₂ reduction process to OH⁻. The calculated electron transfer numbers are in good agreement with the measured low peroxide yield as shown in Figure 6. Thus, compared to C-Cu_{2-x}S, rGO-Cu_{2-x}S not only generated a higher current density, but also is more favorable for efficient oxygen reduction to OH⁻, rather than peroxide.

The best performing rGO-Cu_{2-x}S catalysts were further compared with the state-of-the-art carbon supported platinum (C-Pt). In this comparison, two different Pt standard loadings of 20 and 60 μg/cm² were used as shown in Figure 7. At this point, the catalytic activity of rGO-Cu_{2-x}S is still inferior to that of C-Pt catalysts. However, this work provides a new route to develop nonprecious metal catalysts by tuning the concentration of free hole in degenerately *p*-doped Cu_{2-x}S resulting from cation vacancies. This is significantly different from the extensively studied conventional M-N-C (M: Fe or Co) nonprecious catalysts.²⁷

To provide further mechanistic understanding of the ORR on this new type of Cu-deficient Cu_{2-x}S catalysts, Tafel plots were constructed as shown in Figure 8. According to the K-L equation, the ORR kinetic current densities were calculated from the steady-state polarization and used to plot these Tafel plots. Oxygen reduction in alkaline electrolyte is involved multiple steps due to many possible intermediate species, such as O, OH, O₂⁻, and HO₂⁻. In theory, the rate determining step (RDS) associated with the first-electron transfer yields a Tafel slope of -118 mV/dec. Oppositely, a Tafel slope of -59 mV/dec is due to a migration of adsorbed oxygen

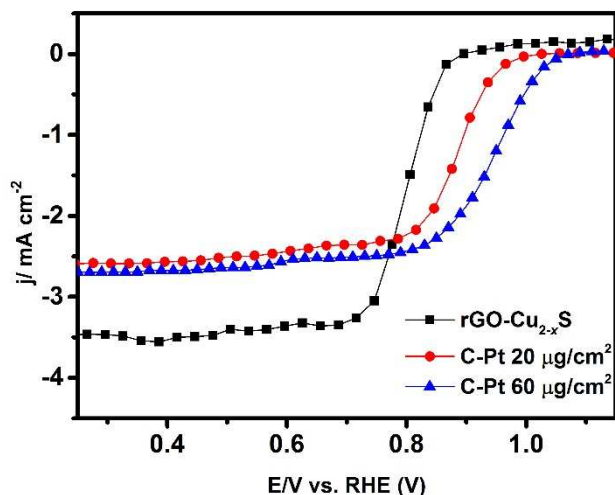


Figure 7. Polarization curves were measured in 0.1 M NaOH solution (room temperature, 900 rpm) for rGO-Cu_{2-x}S and C-Pt. The loading amount of Pt was 20 μg/cm² (red curve) and 60 μg/cm² (blue curve) respectively.

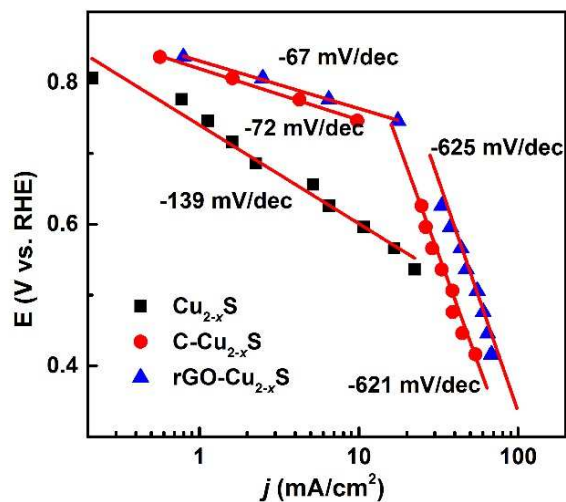


Figure 8. Tafel plots for the ORR on Cu_{2-x}S , $\text{C-Cu}_{2-x}\text{S}$ and $\text{rGO-Cu}_{2-x}\text{S}$.

intermediates on catalysts, resulting from a coverage-dependent activation barrier for the ORR.^{48,50} Here, the standalone Cu_{2-x}S catalysts exhibited a Tafel slope of -139 mV dec^{-1} , suggesting that the first electron transfer during the ORR is likely the slowest step, thereby limiting the overall reaction rates. When carbon supports (XC-72 and rGO) were used to support Cu_{2-x}S , charge transfer is significantly enhanced, showing different Tafel slopes. Both XC-72 and rGO supported Cu_{2-x}S catalysts have similar Tafel slopes. This implies that choice of carbon supports used to enhance catalytic activity does not affect the reaction mechanism. Noteworthy, two well-defined Tafel regions were simulated for these carbon supported Cu_{2-x}S catalysts, with a transition from ca. -70 mV/dec ($E > 0.73 \text{ V}$) to ca. -620 mV/dec ($E < 0.73 \text{ V}$). The Tafel slope of 70 mV/dec at high potential range is between -120 and -59 mV/dec , suggesting that oxygen reduction on carbon supported Cu_{2-x}S catalysts is controlled simultaneously by charge transfer and intermediate migration. At lower potential, the high Tafel slope values is due to that O_2 adsorption onto catalytic sites becomes the RDS.^{51,52}

Conclusion

In this work, we have demonstrated a facile one-pot method to synthesize Cu-deficient Cu_{2-x}S nanoplates with tunable plasmonic properties. The amount of copper precursor supplied was shown to control the copper content and therefore the free hole concentration and LSPR energy at fixed NC size and shape. The newly developed synthesis method only requires a moderate heating ($\sim 85^\circ\text{C}$) of a copper salt and sulfur powder in oleylamine/TOPO solution. The resulting Cu_{2-x}S nanoplates were shown to serve as active electrocatalysts for the ORR in alkaline electrolyte. When Cu_{2-x}S nanoplates were supported

on reduced graphene oxide, a substantial enhancement of activity was achieved, compared to Cu_{2-x}S alone, due to improved electrical conductivity and utilization of active species, along with a very likely synergistic effect between the Cu_{2-x}S and graphene.⁵³ Further understanding of the nature of active sites at the atomic level will first principle calculations and advanced spectroscopic characterization, which will be the subject of future studies. Although the electrocatalytic activity achieved with these first Cu_{2-x}S catalysts is still inferior to the state-of-the-art C-Pt catalysts, this research may open up a new route to develop alternative nonprecious metal catalysts by exploring the novel free-hole-rich Cu-deficient sulfides.

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SUPPORTING INFORMATION AVAILABLE

Additional TEM images, size distributions of NCs, steady-state polarization plots for support materials without Cu_{2-x}S NCs.

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